

Diffraction-Unlimited Plasmonic Metamaterials and Nanolasers

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Dept. of Physics / Center for Condensed Matter
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All Are Welcome!

Abstract

Optical diffraction limits the spatial resolution of light focusing and guiding by conventional lenses, fibers, and waveguides to about the light wavelength. To date, this fundamental limitation remains an insurmountable barrier for optical imaging, lithography, data storage, and integrated systems. Recently, technologies based on plasmon excitation of metal nanostructures by light (nanoplasmonics) has been introduced to overcome the diffraction barrier. In this presentation, I will present new breakthroughs in nanoplasmonics, including plasmonic metamaterials and nanolasers. By using novel metal nanoparticle films and metal-oxide-semiconductor nanostructures, we have realized diffraction-unlimited perfect absorbers and ultralow lasing-threshold plasmonic nanolasers. These are developments represent significant progress toward practical, diffraction-unlimited nanophotonics, which can offer unparalleled capabilities in nanoscience and nanotechnology.

